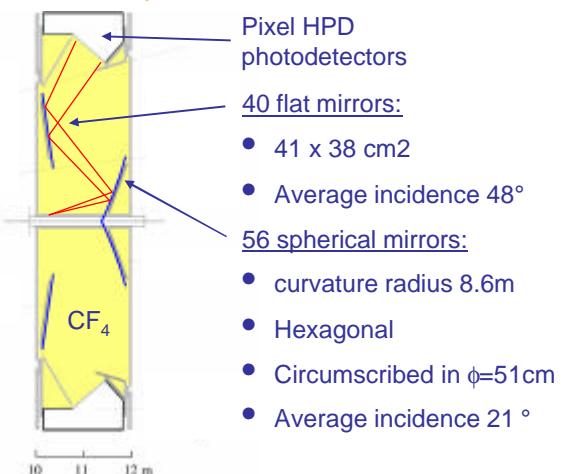
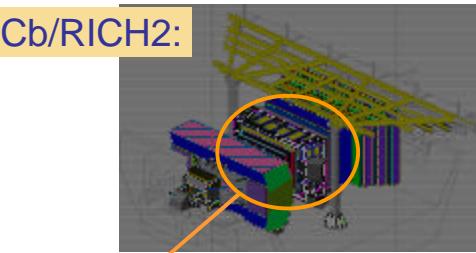


Thin Film coating

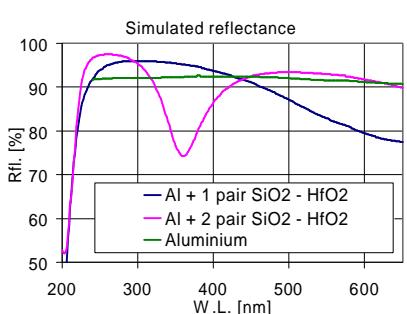
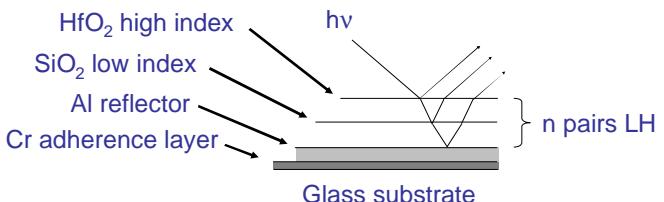
LHCb/RICH2:

Substrates: 6 mm thick polished borosilicate glass

Development of reflective coatings for Ring Imaging CHerenkov detectors

Reflective layers:

Metal reflector + n pairs of low and high refractive index layers for enhanced reflectance in the 200 – 450nm range

1 pair SiO₂-HfO₂:

- Best integral reflectance in spectral range 250 – 450 nm
- Rejection of short wavelength where chromatic aberration is not negligible

Mirror coatings at TA1-SD:



- Large evaporation plant operational at TA1-SD ($\phi 1 \text{ meter}$)
- Electron gun and joule heaters technology



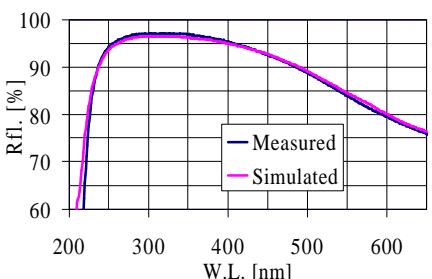
- Reflectance measurements with CERN VUV reflectometer



Series production (~100 mirrors) started June 2004 with a production rate of 2 mirrors per week

Performances:

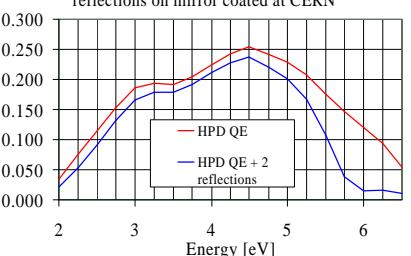
1 pair SiO₂ - HfO₂ on Aluminium reflector measured at 30 deg.



Measured reflectance match the simulations

Reflectance tuned to the spectral response of the HPD photodetector

Simulated efficiency of quartz HPD + 2 reflections on mirror coated at CERN



Hard surface dielectric layer

- efficient protective layers
- easiness for cleaning